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Contents

vii Conference Committee

| | MATERIALS AND MEASUREMENTS I |
|----------|---|
| 12300 02 | 1077-nm, CW mirror thin film damage competition (Keynote Paper) [12300-1] |
| 12300 03 | LIDT testing as a tool for optimization of processing window for D263 glass sheet TGV treatment [12300-2] |
| 12300 04 | Development of a novel large damage site mitigation technique [12300-5] |
| | |
| | MATERIALS AND MEASUREMENTS II |
| 12300 05 | Scanning tunneling microscopy analysis of ultrafast laser damage of single crystal silicon [12300-6] |
| | MATERIALS AND MEASUREMENTS III |
| 12300 06 | Hot-spot monitoring of ArF laser at HDC and high energy mode using low reflective beam splitter [12300-11] |
| 12300 07 | An automated damage inspection microscopy system for National Ignition Facility optics [12300-12] |
| | MINI-SYMPOSIUM ON APPLICATION OF METASURFACE OPTICS FOR USE WITH HIGH-POWER LASERS I |
| 12300 08 | RAR nano-textured diamond pulsed LiDT measurements [12300-16] |
| 12300 09 | Glass-engraved metasurfaces: the path to ultra-low reflectance, extreme broadband performance, and high acceptance angle for high power laser applications [12300-17] |
| | POSTER SESSION: SURFACES, MIRRORS, AND CONTAMINATION |
| 12300 0A | Sub-ps MHz green laser-induced contamination on dielectric coatings in air [12300-61] |

| | MINI-SYMPOSIUM ON APPLICATION OF METASURFACE OPTICS FOR USE WITH HIGH- POWER LASERS II |
|----------|---|
| 12300 0B | Impact of a plasma mitigation process on the 266 nm pulsed LiDT of RAR nano-textured fused silica [12300-22] |
| | SURFACES, MIRRORS, AND CONTAMINATION |
| 12300 OC | UV fatigue of laser optics: laser-induced contamination [12300-29] |
| 12300 0D | A high-power-handling deformable mirror system employing crystalline coatings [12300-30] |
| 12300 0E | Performance of multiple-cone-arrays as shadow cone blockers on NIF [12300-33] |
| | THIN FILMS II |
| 12300 0F | Nonlinear optical switching in thin film coatings in relation to the damage threshold [12300-38] |
| 12300 0G | Sub-ps 1030 nm laser-induced damage threshold evaluation of pulsed-laser deposited sesquioxides and magnetron-sputtered metal oxide optical coatings [12300-39] |
| 12300 OH | Comparison of high power sputtered dielectric mirrors for PW laser [12300-41] |
| 12300 OI | Low absorption metrology of thin film optical components for high power continuous wave lasers [12300-42] |
| | POSTER SESSION: MATERIALS AND MEASUREMENTS I |
| 12300 OJ | Real-time investigation of the UV nonlinear absorptance in an anti-reflective coated LBO crystals [12300-45] |
| 12300 0K | Non-destructive testing of subsurface damage for early indication of laser induced damage threshold in fused silica [12300-48] |
| | POSTER SESSION: MATERIALS AND MEASUREMENTS II |
| 12300 OL | Damage mitigation in the Kagome hollow core fiber used for the delivery of short high-energy pulses [12300-49] |
| 12300 0M | Damage threshold testing of UV optics under a Titan environment for NASA's Dragonfly mission [12300-54] |

POSTER SESSION: THIN FILMS

| 12300 0N | Laser removal of PVD coatings [12300-64] |
|----------|--|
| 12300 0O | Laser conditioning effect for all-silica mirrors [12300-67] |
| 12300 OP | Small-beam damage test scaling for full-aperture damage performance [12300-68] |